



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: Jack O. Chu et al. / : Date: April 1, 2003
Serial No.: 09/989,770 / : Group Art Unit: 2815
Confirmation No.: 2335 / : Examiner: Jesse A. Fenty
Filed: November 20, 2001 : Attorney Docket No.: YOR919980460US2
For: High Speed Composite p-Channel Si/SiGe Heterostructure for Field Effect Devices

Commissioner for Patents
Initial Patent Examination Division
Washington, D.C. 20231

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William
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Response to Restriction Requirement

Sir:

In response to the Requirement for Restriction dated December 18, 2002, Applicants elect Group II, Claims 43-72, drawn to a method of making semiconductor devices, classified in class 438, subclass 1+.

Group I, Claim 42, drawn to a semiconductor device, classified in class 257, subclass 19 is withdrawn from further prosecution and non-elected.

Further favorable action and allowance of the claims is earnestly requested.

Respectfully submitted,
Attorney for the Applicant(s)

By: Robert M. Trepp
Robert M. Trepp
Registration No. 25,933

IBM Corporation
Intellectual Property Law Department
P. O. Box 218
Yorktown Heights, N.Y. 10598
Telephone No.: (914) 945-3147
Fax No.: (914) 945-3281